

2017 RESIDENCY AND EXHIBITION APPLICATION ANU EASS AWARD RESIDENCY

These residency and exhibition opportunities are for two emerging photo-based artist from the ACT or surrounding region graduating from the Australian National University School of Art in 2016. The artists-in-residence will have the opportunity to develop and showcase contemporary photo-based art in a supportive and stimulating artistic environment - receiving technical and creative support and access to PhotoAccess facilities in 2017. The residency is intended to support the completion of one body of work, to be exhibited in the PhotoAccess Huw Davies Gallery in December 2017.

APPLICATION

Name:

Address:

Phone:

Email:

Website:

ABN:

GST registered: yes no

For statistical purposes, do you identify as the following? (optional)

Aboriginal Torres Strait Islander under 26 years old

Please tick items provided as support material:

CV (one page maximum)

digital images 1200 pixels wide, under 1MB each (5 images maximum per application)

PROPOSAL

Concept

What are the ideas and themes behind your residency and exhibition project?

Please provide a brief outline of your project including a rationale outlining the ideas you are wanting to explore. (Maximum 200 words)

Description

What do you aim to produce throughout the residency?

Please provide a brief outline of what you propose to create throughout the residency and for the exhibition (eg. gelatin silver prints, video installation etc.) including the anticipated number and size of works (we understand that this may change). (Maximum 100 words)

Why?

What do you hope to gain from the residency? (Maximum 100 words)

SUPPORT MATERIAL LIST OF IMAGES

Provide past works indicative of the work you intend to produce for the residency exhibition

#	Title of work	Year	Medium	Dimensions
1				
2				
3				
4				
5				

APPLICATION DEADLINE

Applications must be received on or before Friday 18 November 2016

send via email to:
thea@photoaccess.org.au

THE FINE PRINT

Our Emerging Artist Support Scheme (EASS) residency will be offered to two Australian National University School of Art students graduating in 2016*. The residencies will run from mid January 2017 to early December 2017, culminating in two solo exhibitions in the PhotoAccess Huw Davies Gallery (gallery space to be determined) from 1-11 December 2017. The PhotoAccess Huw Davies Gallery has standard opening hours: Tuesday, Wednesday and Friday 10am-4pm, Thursday 10am-7pm, and Saturday and Sunday 12noon-4pm (closed public holidays). PhotoAccess takes a 30% commission on sales.

PhotoAccess provides: Each resident with one year membership to PhotoAccess; technical and creative support throughout the residency and as well as access to equipment, facilities and selected courses and workshops; assistance with the curation, installation, documentation and promotion of the exhibition; basic exhibition catalogue, including an essay or introduction discussing the work and the artist; marketing and promotion of the exhibition; an opening function, including catering; exhibition minding during gallery hours (except for Sundays); sale of works and liaison with buyers.

Artists are expected to: become an active and engaged member of the PhotoAccess community; produce a body of work during the residency, to be exhibited at the conclusion of the residency; assist with preparation of the exhibition catalogue and media material by providing high-res images and an artist statement; provide any hanging equipment they may require, beyond double-sided archival tape; curate, install and pack down the exhibition; make themselves available for interviews and other media activities helping to promote their residency, exhibition and PhotoAccess; be available on Sundays to mind their exhibition and undertake the other responsibilities of Sunday volunteers; present a public talk or demonstration in conjunction with their exhibition.

*Students who are expecting to undertake full-time study for more than 6 months during 2017 are not recommended to apply. If further study will be undertaken during 2017, please note the details in your application.